



Tuning the Optical and Rheological Properties of Host-Guest Systems based on an Epoxy acrylate and MMA

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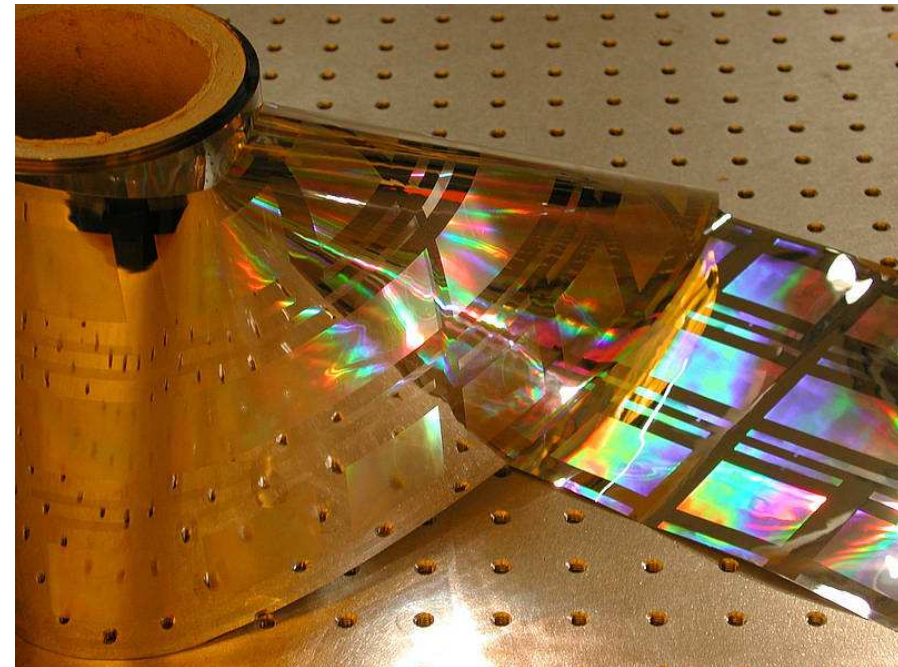
UNI
FREIBURG



DFG

Collaborative Research Center

- Polymer-based sensor network
- Large-area foils
- No electronic components
- Measurement of
 - Temperature
 - Strain
- Sub-projects
 - Suitable materials
 - Construction of fibre optics
 - Light sources
 - Spectrometers / detectors

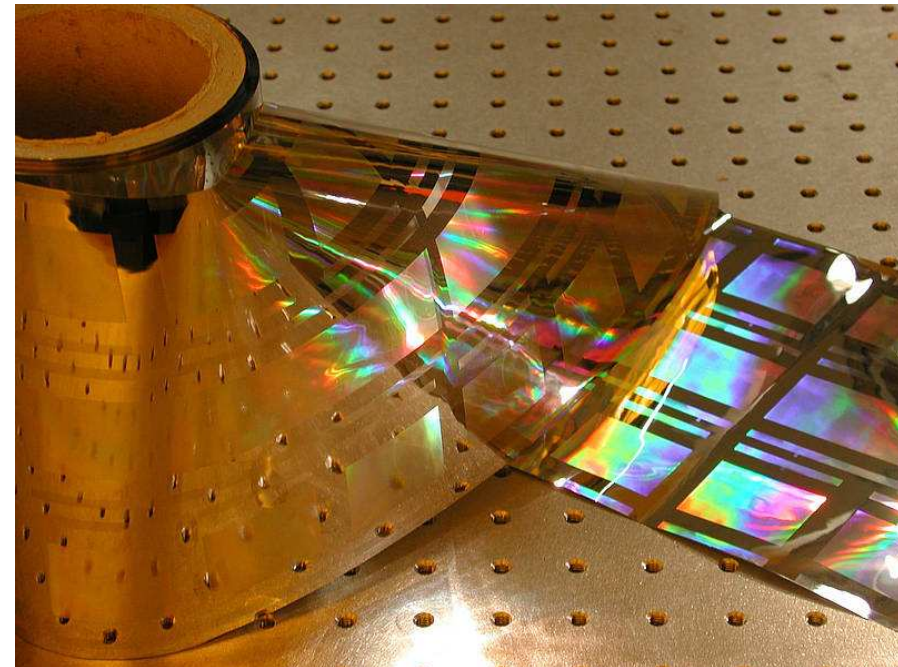


Polymer foil

[<http://www.planos.uni-hannover.de>]

Why polymers?

- Modifiable to application
- Good processability
 - Hot embossing
 - NIL
 - Inkjet-printing
 - ...
- Large-scale systems possible
- Thin layers = economic



Polymer foil

[<http://www.planos.uni-hannover.de>]

Tailored polymers

- Adjusting viscosity
- Polymerization by UV-light
- Adjusting refractive indices
- Low optical damping
- Continuous operating temperature



Tailoring viscosity

- Comonomer content
- Different shaping / molding processes
 - Inkjet printing
 - ≈ 70 mPa·s (@ 70 °C)
 - Offset printing
 - ≈ 200 mPa·s (@ RT)
 - Spin coating
 - ≈ 100 mPa·s – 1000 mPa·s (@ RT)



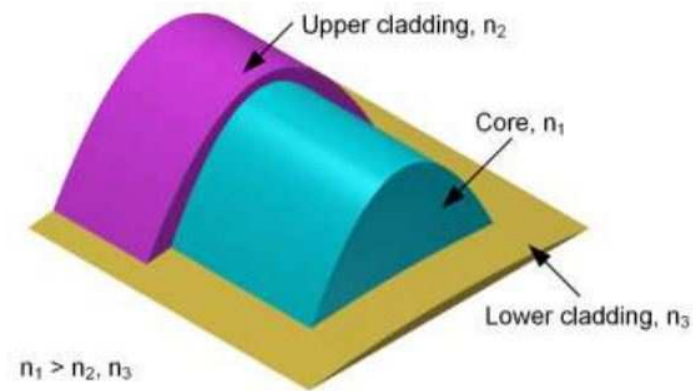
Dimatix DMP 2831 [www.electronic-data.com]



Heidelberg Speedmaster SM 52 [www.heidelberg.com]

Adjustment of refractive indices

- Comonomer / dopant
- Waveguides
 - Core
 - Cladding
- Coupling structures

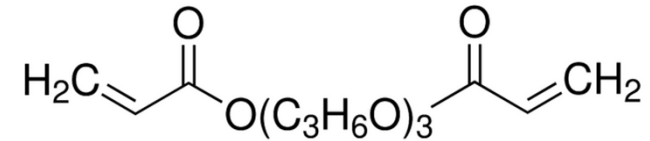


Computed 3D model of printed waveguide (Wolfer, University of Hannover 2013)

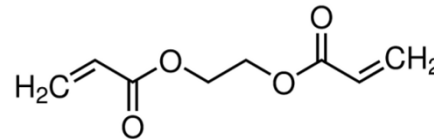
Friday, 11:00 Track 2

Materials

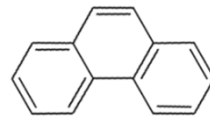
- Prepolymer
 - Syntholux[®] (SYNTHOPOL), 80 % TPGDA



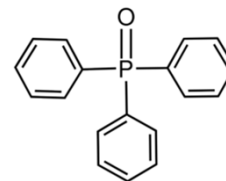
- Comonomer
 - EGDMA



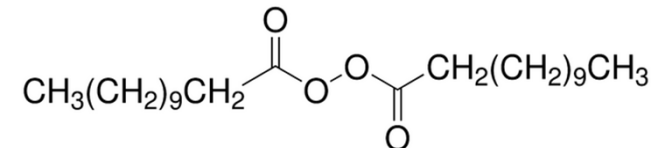
- Dopant
 - Phenanthrene



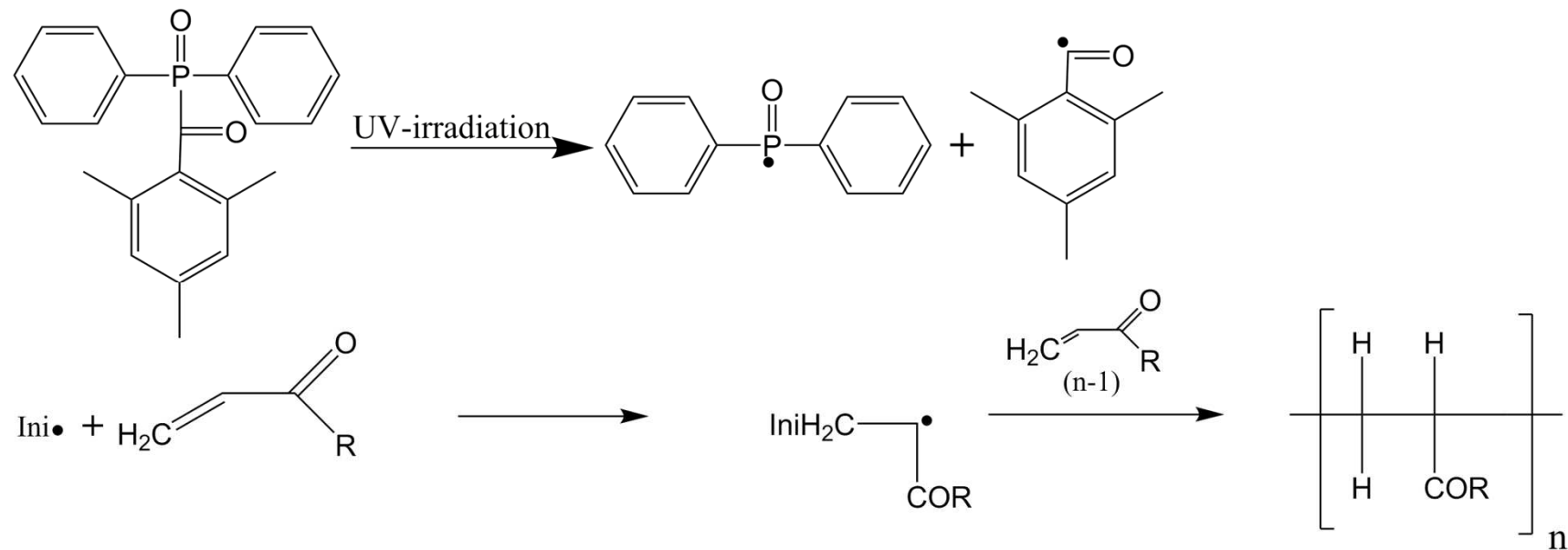
- UV initiator
 - phosphine oxide



- Thermal initiator
 - lauroyl peroxide



Radical polymerization



Mixture preparation

- Materials are dispersed
 - up to 30.000 rpm
 - ambient conditions
- Ultrasonic bath
- Viscosity measurement
 - Cone and plate rheometer



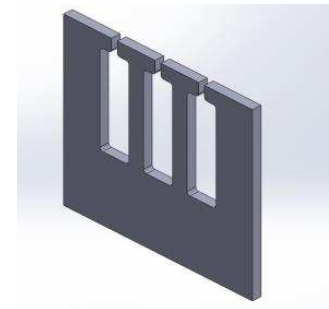
IKA T10 basic
[<http://static.coleparmer.com>]



Bohlin Rheometer CVO 50
[<http://mb.uni-paderborn.de/>]

Sample preparation

- For refractive index
 - Casting mold (silicon)
 - Glass plates
 - Fluorine ethylene propylene (FEP) foil
 - Oxygen inhibition



casting mold

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mold assembly

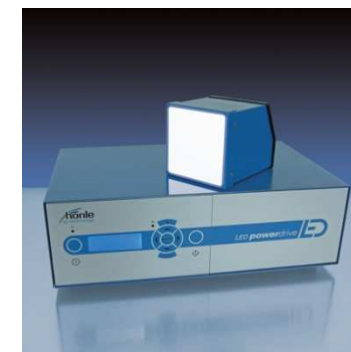
Sample preparation

- For refractive index
 - Casting mold (silicon)
 - Glass plates
 - Fluorine ethylene propylene (FEP) foil
 - Oxygen inhibition

- Polymerization
 - Wavelength 405 nm
 - 8 min, 25 % power



mold assembly



Höppler UV-Spot 100

[www.hoenle.de]

Sample preparation

- For refractive index
 - Casting mold (silicon)
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 - Oxygen inhibition

- Polymerization
 - Wavelength 405 nm
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mold assembly



polymerized sample

Sample characterization

- Refractive indices
 - Abbe-refractometer
 - Multi-wavelength

- Optical damping
 - UV-Vis spectroscopy

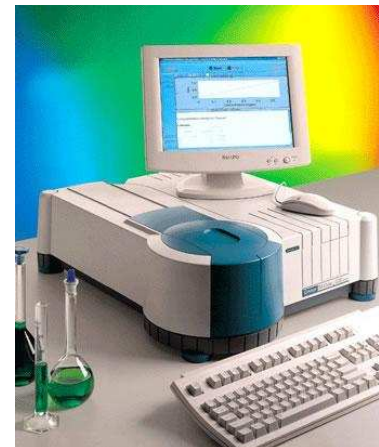
- Differential scanning calorimetry (DSC)
 - Glass transition temperature



ATAGO DR-M2/1550
[www.atagorus.ru]



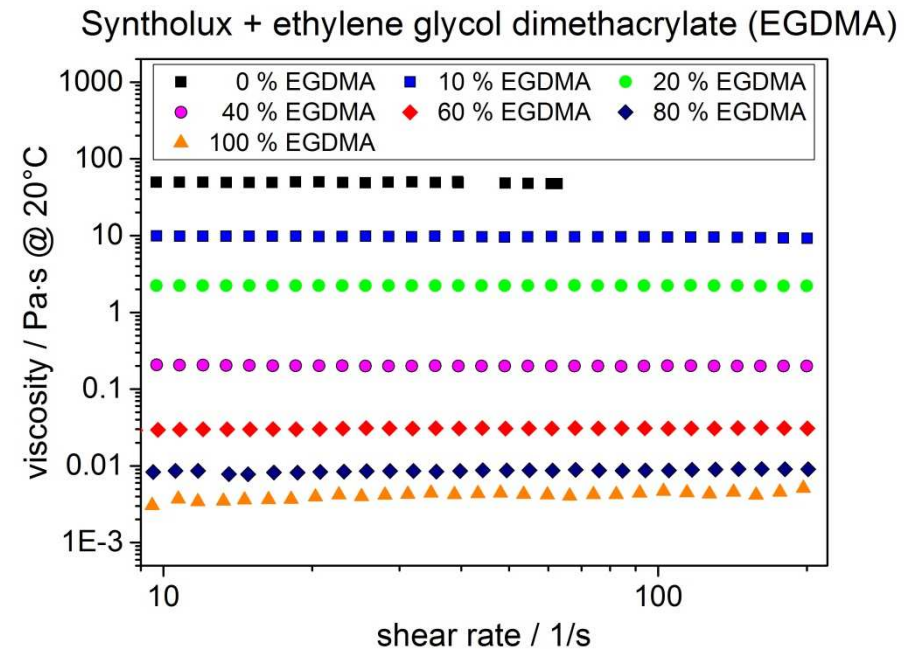
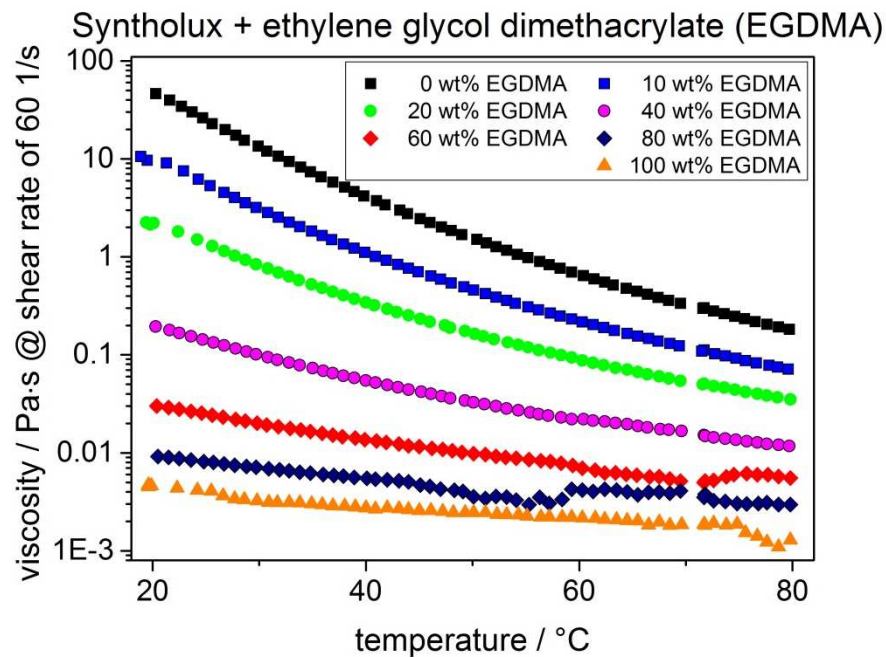
refractometer surface



Varian Cary 50 UV-Vis
[www.speciation.net]

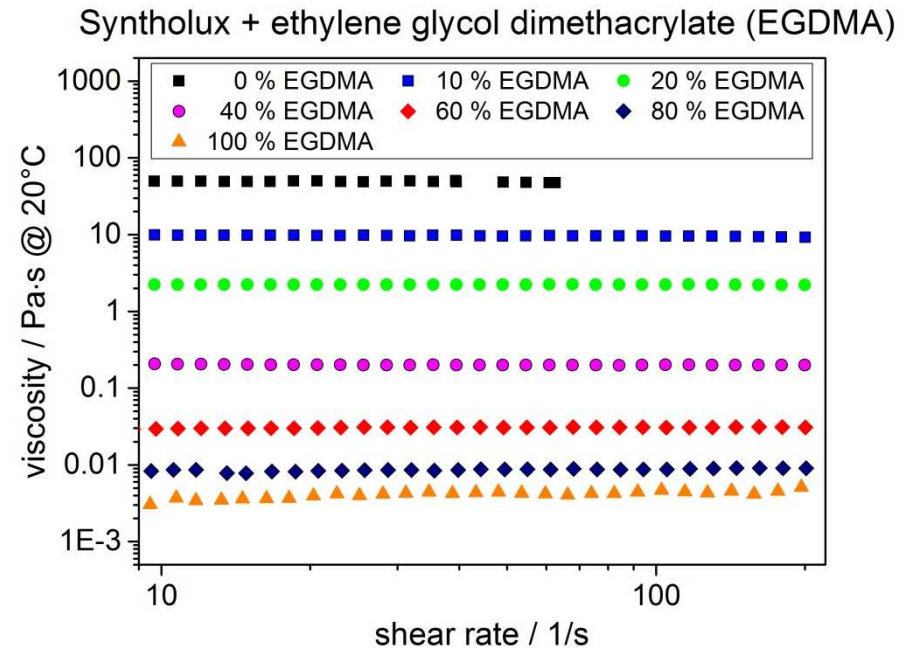
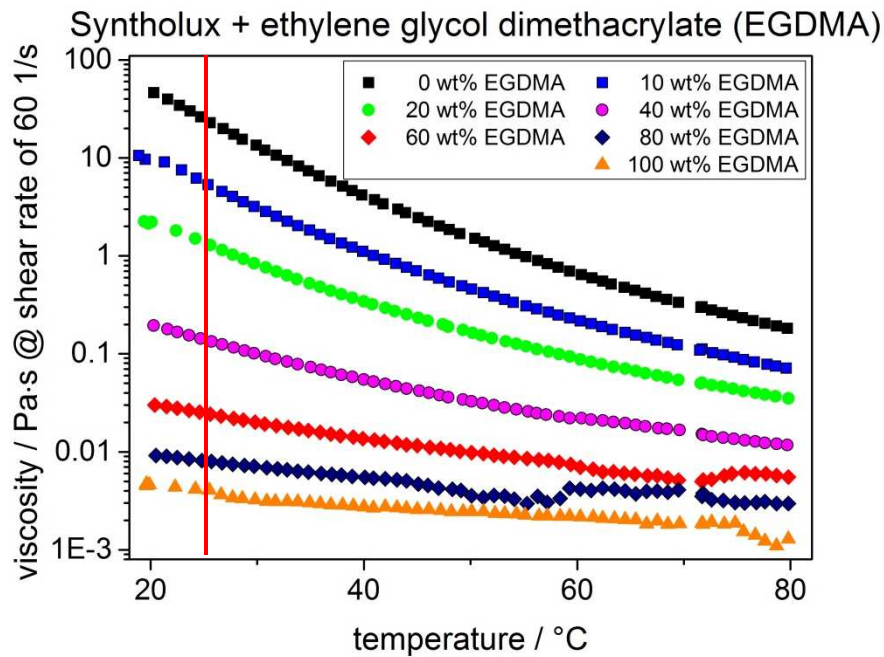
Viscosity Syntholux + EGDMA

- Temperature dependency
- Newtonian behavior



Viscosity Syntholux + EGDMA

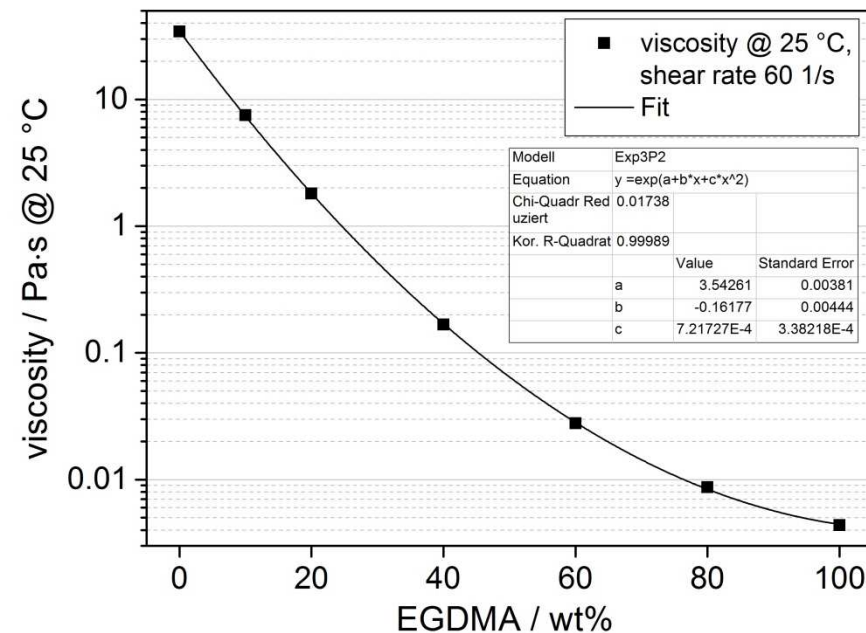
- Temperature dependency
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Viscosity Syntholux + EGDMA

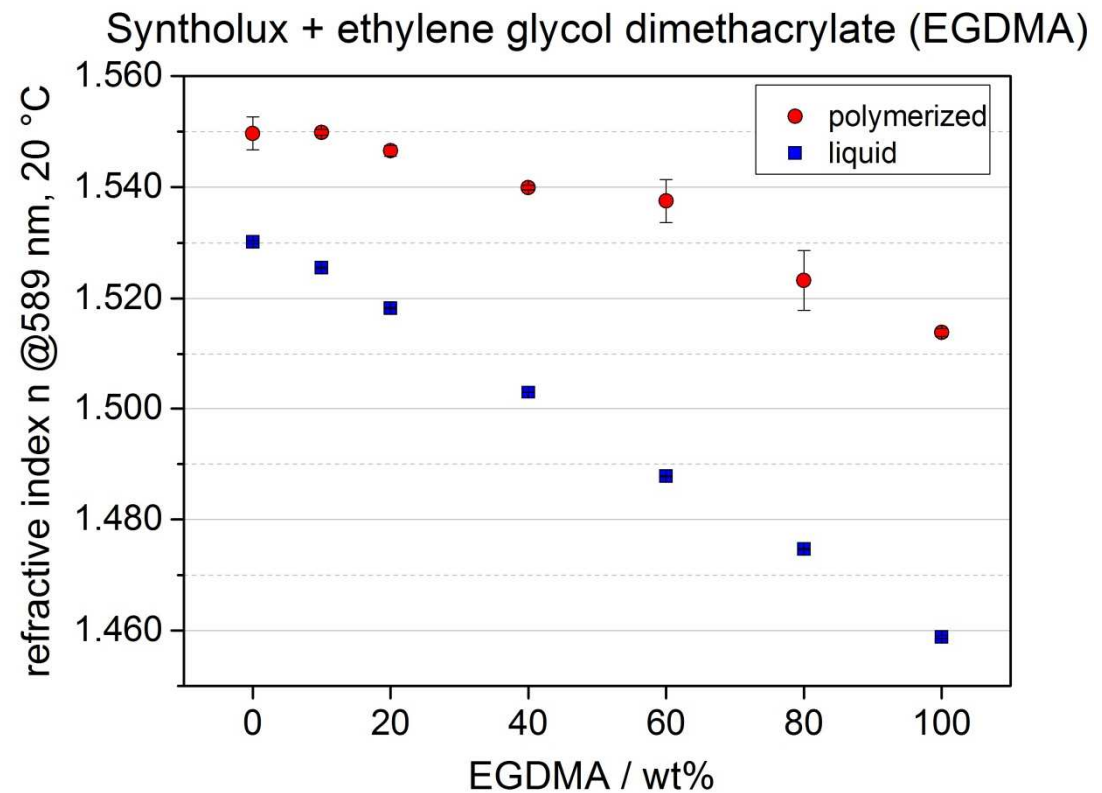
- Temperature dependency
- Newtonian behavior
- Fitting curve for easy lookup

Syntholux + ethylene glycol dimethacrylate (EGDMA)



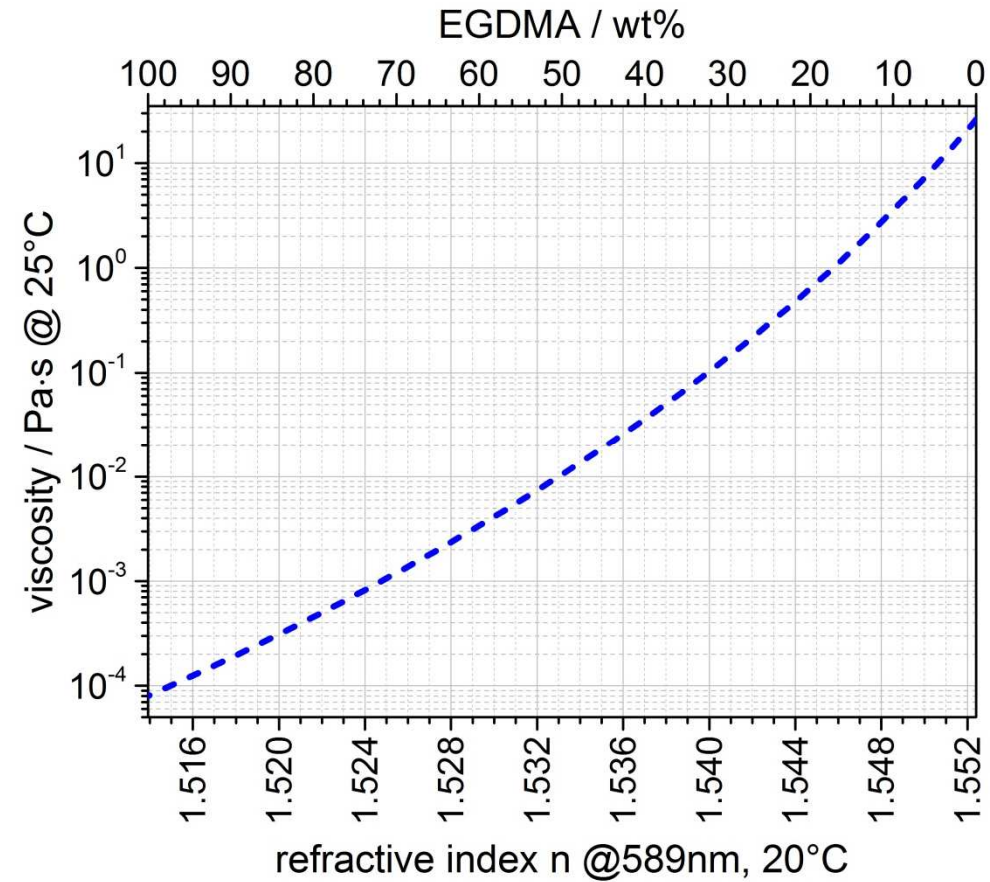
Refractive index

- Liquid
- Polymerized
 - $1.55 > n > 1.515$
 - Shift increases



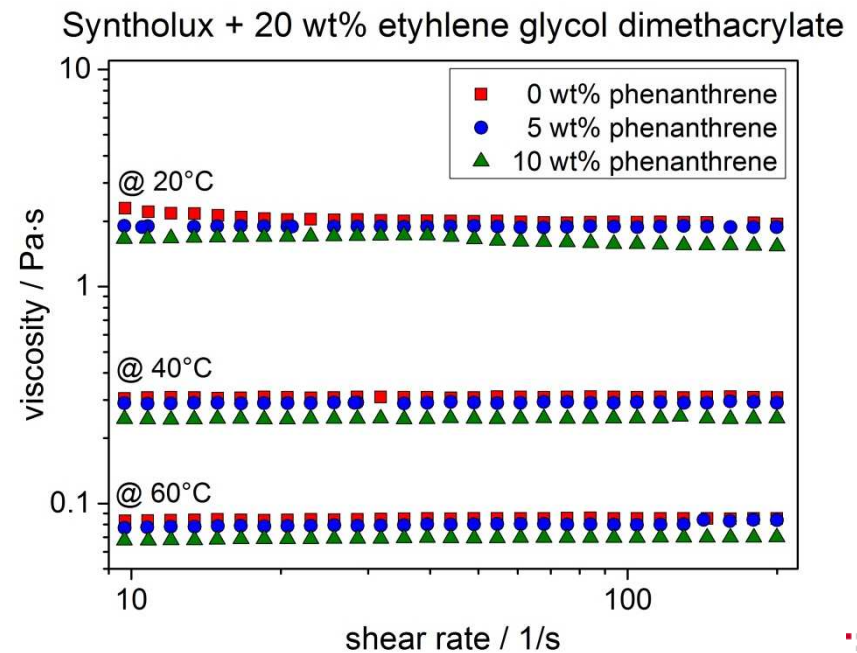
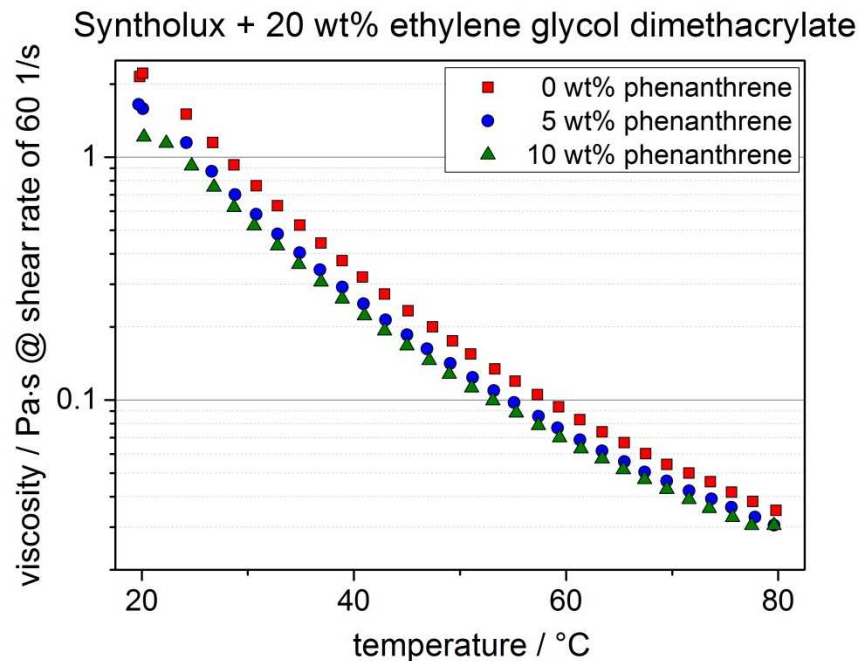
Data combined

- Viscosity
 - Refractive index
- Refractive index
 - Viscosity
- Easy lookup



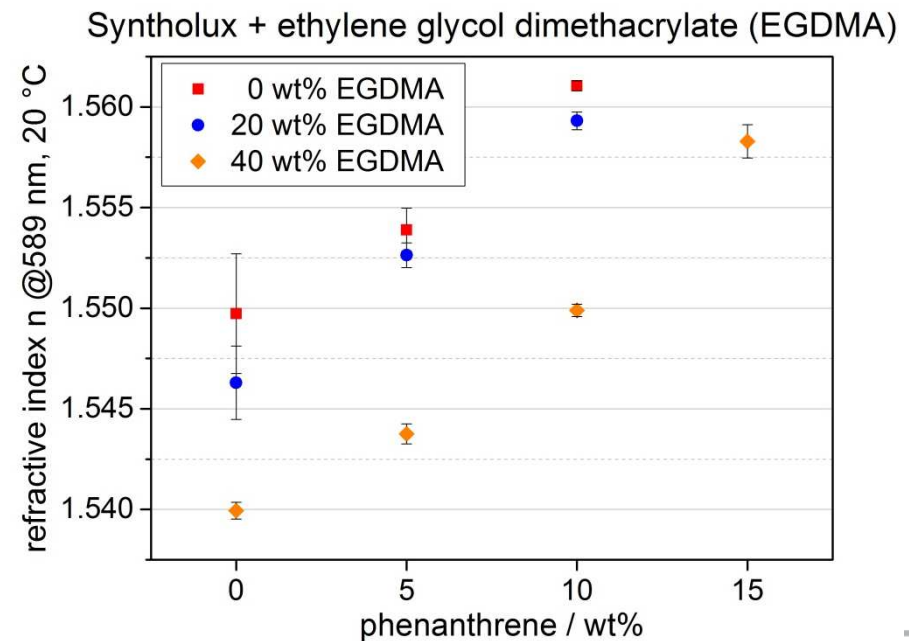
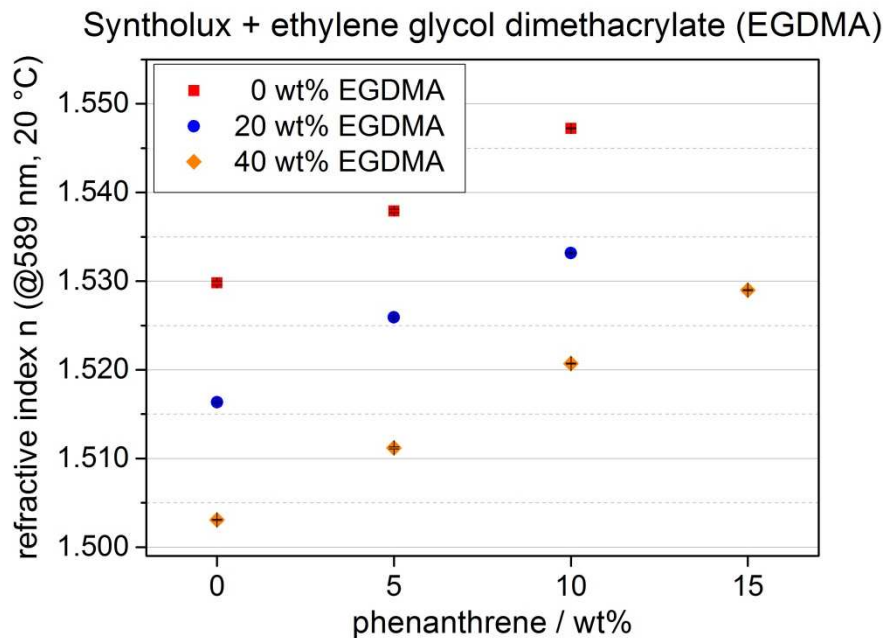
Viscosity Syntholux + EGDMA + phenanthrene

- Temperature dependency
- Newtonian behavior
- Low influence of phenanthrene



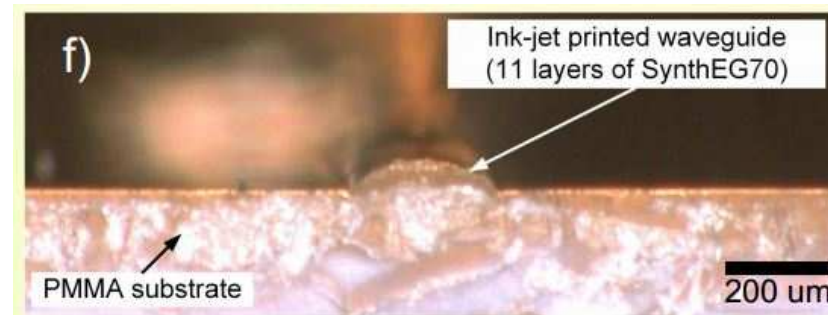
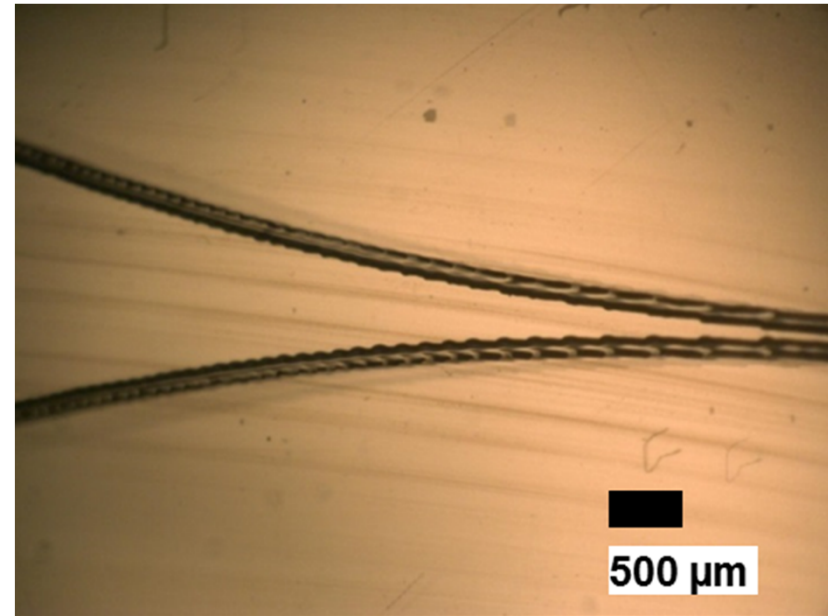
Refractive indices Syntholux + EGDMA + phenanthrene

- Phenanthrene increases refractive index
- Maximum phenanthrene content increases with EGDMA content
- Phenanthrene compensates EGDMA influence



Printed “waveguides”

- Ink-jet
 - width appr. 180 μm
 - height appr. 40 μm

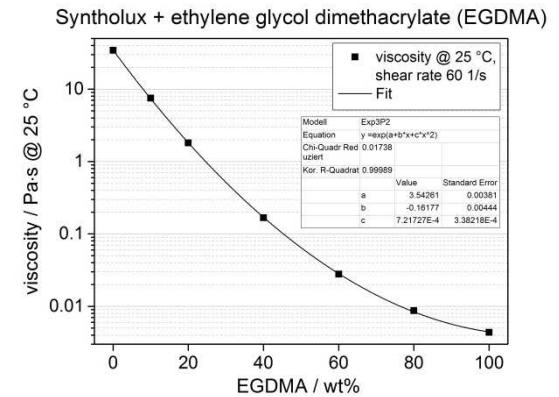


Ink-jet printed waveguides

[Bollgrün, University of Freiburg 2013]

Summary & Outlook

- Viscosity adjustable in a wide range
 - $48 \text{ Pa}\cdot\text{s} > \eta > 4 \text{ mPa}\cdot\text{s}$ (@ 20 °C)
 - Suitable for different shaping methods

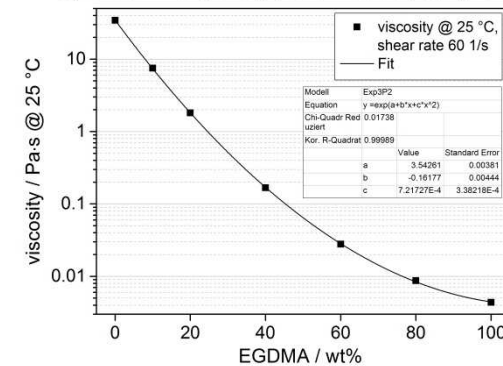


Summary & Outlook

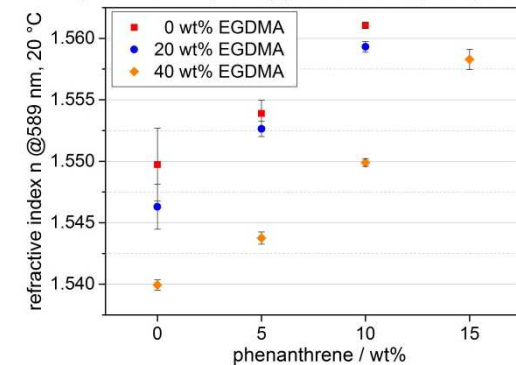
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- Refractive index tunable
 - $1.51 < n < 1.56$ (@ 20 °C, 589 nm)
 - Phenanthrene can compensate influence of EGDMA

Syntholux + ethylene glycol dimethacrylate (EGDMA)



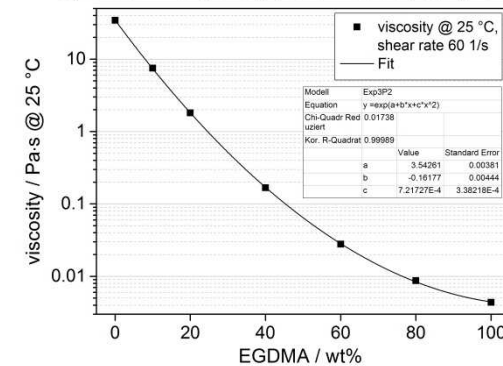
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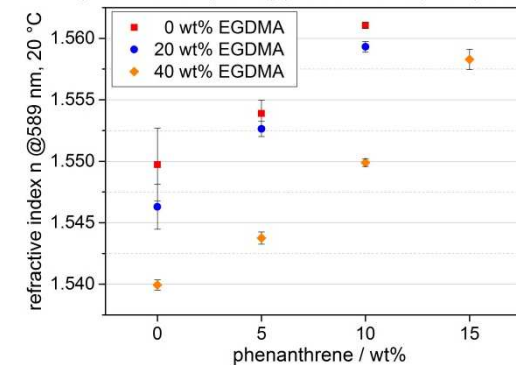
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 - $1.51 < n < 1.56$ (@ 20 °C, 589 nm)
 - Phenanthrene can compensate influence of EGDMA
- Dispersion
 - Abbe number
- Optical damping
- Glass transition temperature

Syntholux + ethylene glycol dimethacrylate (EGDMA)



Syntholux + ethylene glycol dimethacrylate (EGDMA)





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